AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

- 1. (Canceled)
- 2. (Currently amended) A method for fabricating a substrate with a parallax barrier layer, the method comprising:
- (a) preparing a first substrate, which has a first principal surface and a second principal surface that are opposed to each other and which is made of a transparent material;
- (b) providing a parallax barrier layer with a predetermined pattern on the first principal surface of the first substrate;
- (c) forming a first layer, which satisfies a prescribed positional relationship with the parallax barrier layer, on the second principal surface of the first substrate; and

wherein the step (b) includes a step of making a first alignment mark, wherein the alignment mark is formed in the parallax barrier, and step (c) comprises using the alignment mark in the parallax barrier in forming the first layer.

- 3. (Original) The method of claim 2, wherein the step (c) includes a step of locating the first alignment mark through the first substrate and achieving alignment with respect to the first alignment mark.
- 4. (Previously presented) The method of claim 2, wherein the first alignment mark is made of a material of the parallax barrier layer.

- 5. (Previously presented) The method of claim 2, wherein the parallax barrier layer is made of a metallic material.
- 6. (Previously presented) The method of claim 2, wherein the step (c) includes a step of forming a color filter layer as the first layer.
- 7. (Previously presented) The method of claim 2, wherein the step (c) includes a step of forming a black matrix layer as the first layer.
 - 8. (Canceled)
- 9. (Previously presented) A method for fabricating a display device, the method comprising steps of:
 - (A) preparing a substrate with a parallax barrier layer by the method of claim 2;
- (B) securing a second substrate to the substrate with the parallax barrier layer with a predetermined gap provided between the two substrates; and
- (C) forming a display medium layer between the substrate with the parallax barrier layer and the second substrate.
- 10. (Original) The method of claim 9, further comprising a step of (D) dividing a panel, in which the substrate with the parallax barrier layer and the second substrate are combined with each other, into a number of smaller panels after one of the steps (B) and (C).

- 11. (Previously presented) The method of claim 9, wherein the display medium layer is a liquid crystal layer.
- 12. (Original) The method of claim 11, further comprising a step of arranging a polarizer on a viewer-side surface of the parallax barrier layer after the step (D).

13-15. (Canceled)

- 16. (Withdrawn) A method for fabricating a substrate with a parallax barrier layer, the method comprising steps of:
- (a) preparing a first substrate, which has a first principal surface and a second principal surface that are opposed to each other and which is made of a transparent material;
- (b) providing a parallax barrier layer with a predetermined pattern on the first principal surface of the first substrate;
- (c) forming a first layer, which satisfies a prescribed positional relationship with the parallax barrier layer, on the second principal surface of the first substrate; and
- (d) forming a second layer, which satisfies a prescribed positional relationship with the first layer, on the second principal surface of the first substrate.
- 17. (Withdrawn) The method of claim 16, wherein the step (b) includes a step of making a first alignment mark.

IMAI et al Appl. No. 10/522,601

18. (Withdrawn) The method of claim 17, wherein the step (c) further includes a step of making a second alignment mark of a material of the first layer.

19. (Withdrawn) The method of claim 18, wherein the step (c) further includes a step of locating the first alignment mark through the first substrate achieving alignment with respect to the first alignment mark, and

wherein the step (d) further includes a step of locating the second alignment mark and achieving alignment with respect to the second alignment mark.

- 20. (Withdrawn) The method of claim 17, wherein the first alignment mark is made of a material of the parallax barrier layer.
- 21. (Withdrawn) The method of claim 16, wherein the parallax barrier layer comprises metallic material.
- 22. (Withdrawn) The method of claim 16, wherein the step (c) includes a step of forming a first color layer of a color filter as the first layer, and

wherein the step (d) includes a step of forming a second color layer of the color filter as the second layer.

23. (Withdrawn) The method of claim 16, wherein the step (c) includes a step of forming a black matrix layer as the first layer, and

IMAI et al Appl. No. 10/522,601

wherein the step (d) includes a step of forming a first color layer of a color filter as the second layer.

- 24. (Withdrawn) The method of claim 22, further comprising a step of (e) forming a third layer, which satisfies a prescribed positional relationship with the first and second layers, on the second principal surface of the first substrate.
- 25. (Withdrawn) The method of claim 24, wherein the step (e) further includes a step of locating the second alignment mark and achieving alignment with respect to the second alignment mark.
- 26. (Withdrawn) The method of claim 24, wherein the step (e) includes a step of forming a third color layer of the color filter as the third layer.
- 27. (Withdrawn) The method of claim 26, further comprising a step of (f) forming a black matrix layer, which satisfies a prescribed positional relationship with the first, second and third layers, on the second principal surface of the first substrate.
- 28. (Withdrawn) The method of claim 23, further comprising a step of (e) forming second and third color layers, which satisfies a prescribed positional relationship with the black matrix layer and the first color layer, on the second principal surface of the first substrate.

IMAI et al Appl. No. 10/522,601

- 29. (Withdrawn) The method of claim 28, wherein the step (e) further includes a step of locating the second alignment mark and achieving alignment with respect to the second alignment mark.
- 30. (Withdrawn) A method of fabricating a substrate with a parallax barrier layer, the method comprising steps of:
- (a) preparing a first substrate, which has a first principal surface and a second principal surface that are opposed to each other and which is made of a transparent material;
- (b) providing a parallax barrier layer with a predetermined pattern on the first principal surface of the first substrate;
- (c) forming a first layer, which satisfies a prescribed positional relationship with the parallax barrier layer, on the second principal surface of the first substrate, and making an alignment mark, which is used for achieving alignment in forming a second layer which has a prescribed positional relationship with the first layer.